# Absorption coefficients of semiconductor thin films

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**Typical Si PV Cell Structure** 



### Typical Thin Film (CIGS) Cell Structure



Schematic cross section of a typical Cu(InGa)Se<sub>2</sub> solar cell

# Conservation of Energy for each wavelength Total Incident $(\lambda) = A(\lambda) + T(\lambda) + R(\lambda)$



Why must some PV layers be so thick? (want to maximize absorption)

# Mechanisms of Optical Absorption

- Energy is absorbed by a "system", potential energy of system is increased.
- For a system in which we are concerned with gravitational potential energy, consider the energy required to put put a book on a shelf.
- For semiconductors, optical absorption occurs any time a "carrier" can be excited to a higher "state".
- Typically, the carriers we are concerned with are electrons, and the excitation is across the band gap.



## Absorption coefficient

(a connection between the optical and electronic properties of materials)

$$\alpha(\lambda) \propto n_i(\lambda) P_{if}(\lambda) n_f(\lambda)$$

- $\alpha$  ( $\lambda$ ) the absorption coefficient
- $n_i(\lambda)$  density of carriers in an initial state
- $n_f(\lambda)$  density of unoccupied states
- $P_{if}(\lambda)$  probability that transition will take place

In addition to "band gap excitation", another important absorption process is "free carrier absorption", which is typically seen in metals and TCOs.

### Types of Semiconductor Band Gaps



- A direct transition requires just a photon of sufficient energy
- An indirect transition require both a photon and a phonon "two body event" is lower probability.
- Energy and Momentum must be conserved.

# Density of States in 3D Crystal

- "States" allowed solutions to the Shrodinger Equation
- Analogy to waves on a string, but in 3 dimensions





 $\alpha(hv) \propto n_i(hv) P_{if}(hv) n_f(hv)$  $DOS \propto E^{1/2}$  $\alpha(hv) \propto E_i^{1/2} P_{if} E_f^{1/2}$  $\alpha(hv) \propto \Delta E^{1/2}$  $\Delta E = hv - E_g$  $\alpha(hv) \propto \left(hv - E_g\right)^{1/2}$ 

### Absorption Coefficients for some Semiconductors



### 95% Absorption Depth (CdTe)





### Calculation of the absorption coefficient, $\alpha(\lambda)$ , for a thin film



$$T = \frac{I_t}{I_{total}} \qquad I_t = I_0 e^{-\alpha(\lambda)d} \qquad I_0 = I_{total} (1-R)$$

 $I_{t} = I_{total} (1 - R) e^{-\alpha(\lambda)d}$ 

Since  $I_t = (T)(I_{total}) \rightarrow (T)(I_{total}) = (1-R)(I_{total})e^{-\alpha(\lambda)d}$ 

$$e^{-\alpha(\lambda)d} = \frac{T}{1-R} \Longrightarrow \alpha(\lambda)d = -\ln\left(\frac{T}{1-R}\right) \qquad \qquad \alpha(\lambda) = \frac{-\ln\left(\frac{T(\lambda)}{1-R(\lambda)}\right)}{d}$$

#### Measuring the bandgap energy (optical absorption)

$$I(\lambda) = I_0(\lambda) e^{-\alpha(\lambda)x} \quad \blacksquare \quad I(E) = I_0(E) e^{-\alpha(E)x}$$

Direct-gap semiconductor

 $\alpha(E) = \alpha_0 \left( E - E_g \right)^{\frac{1}{2}}$ 



Indirect-gap semiconductor

$$\alpha(E) \propto \left(E - E_g\right)^2$$

 $Fe_2O_3$ , (haematite) – direct or indirect gap?

Semicond. Sci. Technol. **20** No 8 (August 2005) 705-709 doi:10.1088/0268-1242/20/8/009 Nanocrystalline haematite thin films by chemical solution spray J D Desai, H M Pathan, Sun-Ki Min, Kwang-Deog Jung and Oh-Shim Joo

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#### Measuring the bandgap energy (optical absorption)

Direct-gap semiconductor

$$\alpha(E) = \alpha_0 \left( E - E_g \right)^{\frac{1}{2}}$$

		Egr	eV	_		E <sub>gn</sub> eV		
Crystal	Gap	0 K	300 K	Crystal	Gap	0 K	300 K	
Diamond	i	5.4		HgTe <sup>a</sup>	d	-0.30		
Si	i	1.17	1.14	PbS	d	0.286	0.34-0.37	
Ge	i	0.744	0.67	PbSe	d	0.165	0.27	
αSn	d	0.00	0.00	PbTe	d	0.190	0.30	
InSb	d	0.24	0.18	CdS	d	2.582	2.42	
InAs	d	043	0.35	CdSe	d	1.840	1.74	
InP	d	1.42	1.35	CdTe	d	1.607	1.45	
GaP	i	2.32	2.26	ZnO		3.436	3.2	
GaAs	d	1.52	1.43	ZnS		3.91	3.6	
GaSb	d	0.81	0.78	SnTe	d	0.3	0.18	
AlSb	i	1.65	1.52	AgCl		-	3.2	
SiC(hex)		3.0	-	AgI		-	2.8	
Ťe	d	0.33	-	Cu2O		2.172	-	
ZnSb		0.56	0.56	TiO <sub>2</sub>		3.03	-	

"HgTe is a semimetal; the bands overlap.

General references: D. Long, Energy bands in semiconductors. Interscience, 1968; also the A.I.P. Handbook, 3rd ed., Sec. 9.

See, for example, http://engr.sjsu.edu/cme/MatELabs/MatE153/Ch7%20Optical%20 Absorption.pdf, or http://engphys.mcmaster.ca/undergraduate/outlines/3pn4/LAB3P N4-2%20Jan08.pdf Indirect-gap semiconductor

$$\alpha(E) \propto \left(E - E_g\right)^2$$

Indirect gap: plotting  $\alpha$  vs E shows an E<sup>2</sup> dependence, so plotting  $\alpha^{1/2}$  shows a linear dependence.

Direct gap: Plotting  $\alpha$  vs E shows an E<sup>1/2</sup> dependence, so plotting  $\alpha^2$  shows a linear dependence.

#### Measuring the bandgap of a thin film (optically)



Therefore, if a plot of hv versus  $\alpha^2$  forms a straight line, it can normally be inferred that there is a direct band gap, measurable by extrapolating the straight line to the  $\alpha = 0$  axis. On the other hand, if a plot of hv versus  $\alpha^{1/2}$  forms a straight line, it can normally be inferred that there is an indirect band gap, measurable by extrapolating the straight line to the  $\alpha = 0$  axis. From http://en.wikipedia.org/wiki/Direct\_and\_indirect\_band\_gaps

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		Ener	gy gap	Lowest conduction- band minimum, direct or indirect	$\int_{0}^{1-} \left(\frac{dE_g}{dT}\right) \times \frac{10^4}{(300^\circ \text{K})} \\ e \text{V/}^\circ \text{K}$	$\left(\frac{dE_g}{dP}\right)_T \times 10^6$ eV/bar	Effective mass				Lattice	Mobility	
		Es (0°K) eV	Eg (300°K) eV				m*,	m#	Refractive index n	Static dielectric constant $\epsilon$	constant a Å	μ <sub>e</sub> cm²/ V•sec	μ <sub>h</sub> cm <sup>2</sup> / V-sec
	Si	1.166	1.11	ind 100	-2.3	-1.5	$m_l 0.98 \\ m_l 0.19$	0.52	3.44	11.7	5.43	1,350	480
1	Ge	0.74	0.67	ind 111	-3.7	5.0	m <sub>1</sub> 1.58 m <sub>1</sub> 0.08	0.3	4.00	16.3	5.66	3,900	1,900
	la-Sn	-0.2‡		dir 000		5.0	0.02				6.489	2.000	1.000
IV-I	v sic $\begin{cases} \alpha \\ \end{cases}$	3.0 (6H)	2.8-3.2†	ind	-3.3				2.69 // c 2.65 1 c	10.2	a 3.0817 c 15.1123	400	
	(B	2.68	2.2	ind							4.359		
1	Se	1.95	1.74	dir 0001	-14	- 20		0.12	5.56∦c 3.72⊥c	8.5		1	
	Te	0.334	0.32	dir 0001	-0.3	-19	0.038 <sub>⊥</sub>	0.26 # 0.10 ±	3.07∥c 2.68⊥c	5.0∦c 2.2⊥c		1,100	
			-				1		2.6	6.9	4.538	1	
AIP	BP		2	ind	2.6		0.12+		3.0	9.8	5.462	80	
	AIP	2.5	2.43	ind 100	-3.5		0.5	mi 1.06	510	12	5.66	1,000	~100
- 1			-1.0	1.4.100		16	0.11	0.39	3.4	11	6.135	50	400
AISb GaN GaP GaAs GaSb InP InAs InSb	AISb GaN	1.6	3.4	dir 0000	-4.8	4.2	0.2	0.8	2.4	12	a 3.18 c 5.16	300	
	Gard	2.5	0.00	104 100	5.4	17	0.13	0.678	3.37	10	5.450	120	120
	GaP	2.4	2.25	100 100	-3.4	-1.7	0.07	0.5	3.4	12	5.653	8,600	400
	GaAs	1.520	1.43	dir 000	- 3.0	12	0.045	0.39	3.9	15	6.095	4,000	650
	GaSb	0.81	0.69	dir 000	-4.1	4.6	0.07	0.40	3.37	12.1	5.8687	4,000	000
	InP	1.42	0.26	dir 000	- 13		0.028	0.33	3.42	12.5	6.058	30,000	Z41
	InAs	0.43	0.36	dir 000	-2.9	15	0.0133	0.18	3.75	18	6.4787	76,000	(78°K
	700		3.2	dir 0000	-9.5	0.6	0.32	0.27	2.02	7.9	a 3.2496 c 5.2065	180	
	Lino		3.8	dir 0000	- 3.8	9	0.28	>1 /	2.4	8.3	g 3.814 c 6.257		
ZnS { ZnSe ZnTe II-VI CdS CdSe	ZnS {"		- 2.6	2:- 000	51	57	0.39		2.4	8.3	5.406		-
	LB		3.0	dir 000	-12	6	0.17		2.89	8.1	5.667	100	-
	ZnSe	2.80	2.38	dir 000	-5	6	0.15		3.56	9.7	6.101		1 /
	ZnTe	2.58	2.53	dir 0000	-5	3.3	0.20	0.7⊥c 5 ∦c	2.5	8.9	a 4.136 c 6.713	210	-
	CdSe	1.85	1.74	dir 0000	-4.6		0.13	2.5∦‡ 0.4⊥		10.6	a 4.299 c 7.010	500	-
	C.IT.	1.60	1.50	dir 000	-41	1.5	0.11	0.35	2.75	10.9	6.477	600	
	Cale	1.00	25	011 000						-	6 402	5 500	+
	HeSe	- 0.24	-0.15	dar 000			0.045			25	6.085	3,300	100
Pt	HgTe	-0.28	-0.15	dir 000	+ 5.6		0.029	~0.3	3.7	20	6.42	22,000	(20°K
	The	0.29	0.37	dir 111	+4	-7	0.1	0.1	3.7	170	2.930	530	000
	PbSe	0.15	0.26	dir 111	+4	-8	m1 0.07 m1 0.039	m1 0.06 m1 0.03		250	6.124	1,020	930
V-VI	PbTe	0.19	0.29	dir 111	+4	-9	m <sub>1</sub> 0.24 m <sub>1</sub> 0.02	m; 0.3 m; 0.02	3.8	412	6.460	1,620	750
		0.1	0.18	dir 111				and a state of the state of the		-	0.328		

#### Reproduced From "Optical Processes in Semiconductors", Pankove